Effects of Zn Doped TiO2 on the Performance of Perovskite Solar Cells

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Abstract – *The work focuses on the effects of Zn-doped TiO₂ <i>as the Electron Transport Layer in MAPbI3 based Perovskite Solar Cells with a carbon-based back electrode fabricated under controlled ambient conditions. Varying molar percentages of Zn-doped TiO2 of 0, 0.5, 1, 2, and 5 mol%* were successfully incorporated into the TiO₂ crystal structure using the sol-gel technique. *Characterization through X-ray diffraction and Energy Dispersive X-ray spectroscopy confirmed the incorporation of Zn ions. The crystallite size ranged from 19.99 to 7.1 nm, depending on the Zn ion doping concentration. Fourier Transform Infrared spectroscopy verified the presence of the anatase phase of Zn-doped TiO2 at wavenumber 438 cm-1 . Scanning Electron Microscope images exhibited fairly smooth and uniform surface coverage for the Zn-doped TiO2 layers. The Rq* values for surface roughness showed a decrease from 26.85 nm for undoped TiO₂ to 23.4 nm *for the 5 mol% Zn-doped TiO2 layer. UV-Vis spectroscopy demonstrated low light transmission loss characteristics from 300 to 790 nm, with the 2 mol% Zn-doped TiO₂ showing slightly improved light transmission between 550 and 800 nm. The bandgap energy of undoped and Zndoped TiO2 ranged from 3.53 to 3.38 eV. An optimum power conversion efficiency of 5.67% was achieved with a 2 mol% dopant concentration. However, increasing the Zn dopant to 5 mol% led to a slight deterioration in the PCE. According to the optimized ETL processing for the PSC, the Jsc increased from 12.2185 mA/cm2 to 12.25594 mA/cm2 , the Voc increased slightly from 0.90569 V to 0.9231 V, and the PCE from 5.199% to 5.67%.*

Keywords: Conduction Band (CB), Perovskite Solar Cells (PSC), Power Conversion Efficiency (PCE), Titanium dioxide, Zn doped

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I. Introduction

Perovskite, which has the general crystal structure ABX3, is the absorber component used in perovskite solar cells (PSCs). The perovskite form of ABX₃ with methyl ammonium (CH3NH3) as (A), metal such as lead (Pb) or tin (Sn) as (B) , and a halide bromide (Br_3) , iodide (I_3) , or chloride (Cl_3) as (X_3) has so far been used to make the most effective PSC devices [1]. Perovskite has the following advantages: a low band gap that permits greater light absorption, a high carrier charge mobility that enables the generated electron and hole to move through the substance with little resistance, and a high diffusion length that inhibits electron-hole pair recombination [2].

Metal oxides such as zinc oxide (ZnO) [3], aluminum oxide (Al_2O_3) [4], tin oxide (SnO_2) [5], and titanium dioxide $(TiO₂)$ have been used as the ETL to improve electron transportation and the PCE. TiO2 exhibits attractive characteristics such as chemical stability, low cost, and high transport ability [6]. This is attributed to the conduction band (CB) of $TiO₂$ being lower than the conduction band of the perovskite

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absorber layer, facilitating the electron transport from the perovskite layer to the $TiO₂$ layer [6].

For the PSC to function effectively, the energy levels for each layer, as shown in Fig. 1, must be carefully aligned. This is accomplished by having the lowest unoccupied molecular orbital (LUMO) of the ETLs slightly lower than that of the active layers, which provides an electron with a more desirable path to travel.

The same applies to the HTLs HOMO (highest occupied molecular orbital), which must be slightly higher than the active layers HOMO to offer a more attractive path for holes. This is similar for each layer in the cell; each layer must have either a greater HOMO or a lower LUMO in order for the charge carriers' transportation chain to function [7].

Materials are doped to increase charge carrier conductivity by adding an extra molecule to their structure. Doping changes the band structure and trap states of $TiO₂$, altering important properties such as conduction band energy, charge transport, recombination, and collection $[8]$. TiO₂ doped with Mg, Nb, Y, Al, and Zr has previously been used in perovskite solar cells. Mg-doped HBL/ ETL has improved V_{OC} because of its strong conduction band and low recombination [9]. Nb doping boosted electron injection and transport, resulting in greater JSC [10], and Y doping improved performance due to increased perovskite loading, resulting in significant increases in JSC and marginally reduced recombination [11]. It has been found that Al-doping reduces the number of oxygen vacancies and the associated deep trap states, lowering recombination and increasing film conductivity. As a result, J_{SC} increased overall [12]. Doping TiO₂ with Zr^{4+} reduced hysteresis while pushing the CB upward and reducing recombination, resulting in an increase in VOC [13, 14].

These results suggest that doping is important in lowering surface trap states, reducing hysteresis, and enhancing current density. Overall, these results suggest that $TiO₂$ doping and co-doping are expected to play an important role in lowering surface trap states, reducing hysteresis, enhancing current density, and improving PSC efficiencies. Doping causes the CB to shift, hence increasing charge transfer and decreasing recombination. Additionally, it has the ability to increase perovskite loading, lengthen device lifetimes, and play a vital role in reducing hysteresis [15].

Recent advancements in perovskite solar cell technology have highlighted the need for improved electron transport layers. This research focuses on the use of Zn -doped $TiO₂$ compact layer with variable doping concentrations of $0, 0.5, 1, 2$ and $5 \text{ mol } \%$ as an electron transport layer. A number of n-i-p structure perovskite solar cells were developed. The Zn-doped

TiO2 compact layers' structural, morphological and optical properties are also analyzed and discussed. The photovoltaic properties of perovskite solar cells with various Zn-doped $TiO₂$ compact layers as electron transport layers are discussed. The research addresses the need to improve the electron compact layer, which will aid in developing future highly efficient perovskite solar cells using carbon-based electrodes.

Fig. 1. Energy level band diagram

II. Materials

All chemicals used in the fabrication of the ETL, perovskite and HTL are listed in Table I and were purchased from Sigma-Aldrich Co.

III. Device Fabrication *A. Substrate Preparation A. Substrate Preparation A. Substrate Preparation*

A. Substrate Preparation \sum

Fluorine-doped tin oxide (FTO) coated glass substrates of 25 mm x 25 mm with a thin film thickness substrates of 25 nm x 25 nm with a thin rinn directives of 100 nm and sheet resistance of 8.3 Ω were cleaned in or roo in and succervessance of 8.3 **s2** were eleaned in a beaker containing detergent and deionized water. Each a beaker containing detergent and deformated water. Each substrate was then rinsed in an acetone before being
placed in the ultrasonic cleaner. The substrates were
then immersed for 20 minutes at 80 $^{\circ}$ C in the ultrasonic placed in the unrasonic creaner. The substrates were then immersed for 20 minutes at 80 $^{\circ}$ C in the ultrasonic $\frac{1}{20}$ minimized for 20 minimized at 60 °C for the unrasome cleaner containing ethanol. The substrates were removed eleance containing culation. The substrates were removed
and placed into a beaker containing deionized water and placed into a beaker containing deformation water
before being placed on a hotplate at 60 °C for 10 before being placed on a hotplate at 60 °C for 10
minutes or until totally dry. The substrates were then
placed for 20 minutes in an Ultra Violet Ozone (UVO) minutes or until totally dry. The substrates were then
placed for 20 minutes in an Ultra-Violet Ozone (UVO) practure for 20 minutes in an unital violet of the (0 v)
cleaner to break down organic surface impurities and provide an ultra-clean surface for the deposition of the ETL layer. *B. Zn – doped ETL layer preparation and deposition*

B. Zn – doped ETL layer preparation and deposition combined with 7.29 minutes for 3 minutes for 3 minutes for 3 minutes for 3 minutes and minutes for 3 minutes for 3 minutes and 4.3 minutes for 3 minutes and 4.3 minutes for 3 minutes and 4.3 minutes and 4.3 minutes and 4.3 B. Zn – doped ETL layer preparation and deposition

In a volumetric flask, 40 ml di-ionized water was in a volumetric hask, 40 ml ut-fold water was
combined with 7.29 ml HCL and mixed for 3 minutes $\frac{1}{2}$ before adding additional de-ionized water up to 100 ml combined with 7.29 ml HCL and mixed for 3 minutes
before adding additional de-ionized water up to 100 ml
to obtain a 2M HCL stock solution. To prepare the 0.22 to botam a 2NI HCE stock solution. To prepare the 0.22
M TiO₂ precursor solution with Zn doping of 0.5 , 1, 2, 5 to 1602 precursor solution with Σ and deping or 0.9, 1, 2, 9 mol%, the required amount of Σ inc Chloride was added not to 14.29 ml ethanol and stirred vigorously at 6000 rpm to 14.29 ml ethanol and stirred vigorously at 6000 rpm
for 30 minutes, then 0.28 ml of the 2M HCL stock
solution was slowly added and stirred vigorously at for 30 minutes, after 0.26 minutes and stirred vigorously at solution was slowly added and stirred vigorously at solution was slowly added and stirred vigorously at 6000 rpm for an additional 30 minutes, after which 1 ml of TTIP was slowly added and stirred for 2 hours. The of TTIP was slowly added and stirred for 2 hours. The
resulting solution was then filtered using a 0.45 µm Teflon filter before spin coating to ensure the removal of T FETO FIRCH SUGGE SPIN COATING to CHISTIC THE FEIND SATTLE SPIN COATING SUBSTRATE IN FEIND SATTLE sman particles to botain a smooth and unflorm surface
coverage. The FTO substrates were then pre-heated to 60° C before dynamically spin coating 300 μ l of the Zn- $\frac{d}{dt}$ of $\frac{d}{dt}$ correct ay halo realize the catalogue of $\frac{d}{dt}$ or an analysis of $\frac{d}{dt}$ or $\frac{d}{dt}$ on $\frac{d}{dt}$ correction at 1000 rpm for 15 $\frac{1}{\pi}$ seconds and annealed on a ceramic digital hotplate at seconds and anneated on a ceranne digital holpiace at 550 °C for 30 minutes to form the Zn-doped ETL thin f_{350} \sim to f_{30} minutes to form the Zn-doped ETE thin film layer. This layer was then UVO treated for 15 minutes prior to the deposition of the methyl ammonium lead iodide precursor solution. *C. Perovskite layer preparation and deposition C. Perovskite layer preparation and deposition* 6000 rpm for an additional 30 minutes, after which 1 ml doped ELT precursor solution at 1000 rpm for 15 film layer. This layer was t

C. Perovskite layer preparation and deposition C. Perovskite layer preparation and deposition

To prepare the perovskite precursor solution, 0.16 g of methyl ammonium iodide and 0.46 g of lead iodide $\begin{array}{ccc} \n\text{and} & 0.6 \text{ ml} \n\end{array}$ of dimethylformamide (DMF) and measurements were carried out usin were added to 0.08 ml of dimethyl sulfoxide (DMSO) characteristics. The photolumin magnetically stirred at 3000 rpm for 24 hours. Then 250 µl of the perovskite solution was statically spin-coated at 5000 rpm for 15 seconds, with 350 µl of di-ethyl ether slowly dripped from a distance of about 2 cm from the revolving substrate during the final 5 seconds. To develop the dark brown and semitransparent perovskite

layer, the coated surface was placed on a digital hotplate layer, the coated surface was placed on a digital hotplate
at 65 $^{\circ}$ C for 1 minute, then slowly ramped up to 100 $^{\circ}$ C
and annealed for 2 minutes. This was then placed in a and annealed for 2 minutes. This was then placed in a vacuum desiccator for 3 hours before deposition of the vacuum desiccator for 3 hours before deposition of the ractum accreditor for 2 notes certain appointm of the wave the transport layer to minimize exposure to oxygen and hole transport layer to minimize exposure to oxygen and humidity. h_{matrix} . humidity. layer, the coated surface was placed on a digital hotplate

D. HTL preparation and deposition D. HTL preparation and deposition D. HTL preparation and deposition

D. F. J. Preparation and deposition and deposition vigorously for 10 minutes to form the LiTFSI stock solution. Then, 0.07 g of Spiro-OMeTAD powder was solution. Then, $0.07 \, \text{g}$ of Spiro-OMETAD powder was added to 1 ml chlorobenzene and stirred vigorously for 10 minutes to form the Spiro-OMeTAD solution. After this 0.03 ml of tBP and 0. 02 ml of the LiTFSI solution this 0.03 ml of the Spiro-OMeTAD solution and stirred was added to the Spiro-OMeTAD solution and stirred for 30 minutes. Thereafter, 200 µ was dynamically spincoated at 1000 rpm for 15 seconds and placed in a vacuum desiccator overnight before applying \sim 8 mg of vacuum desiccator overnight before applying \sim 8 mg of activated carbon powder and FTO to form a metal-free back conductive electrode. 0.52 g of LiTFSI in 1 ml acetonitrile and stirring 0.52 g of LiTFSI in 1 ml acetonitrile and stirring 0.52 g of LiTFSI in 1 ml acetonitrile and stirring added to 1 ml chlorobenzene and stirred vigorously for added to 1 ml chlorobenzene and stirred vigorously for added to 1 ml chlorobenzene and stirred vigorously for 10 minutes to form the Spiro-OMeTAD solution. After
this 0.03 ml of tBP and 0.02 ml of the LiTFSI solution
was added to the Spiro-OMeTAD solution and stirred activated carbon powder and FTO to form a metal-free activated carbon powder and FTO to form a metal-free activated carbon powder and FTO to form a metal-free The hole transport layer was prepared by dissolving The hole transport layer was prepared by dissolving 10 minutes to form the Spiro-OMeTAD solution. After

back conductive electrode. *E. Synthesis Zn- doped TiO2 nanoparticles E. Synthesis Zn- doped TiO2 nanoparticles*

Zn-doped ETL precursor solution was aged for 72 days to form a clear and transparent gel. The gel was then dried for 12 hours at 80 °C in a hot air dryer to obtain dry TiO₂ powder. After drying, the TiO₂ powder is $\frac{1}{2}$ heated for $\overline{30}$ minutes at $\overline{550}$ °C in a furnace to produce analysis and 150° C m a funded to produce
analysis for FTIR, XRD, and TEM heated for 30 minutes at $\frac{1}{2}$ in a function $\frac{1$ *E. Synthesis Zn- doped TiO2 nanoparticles* investigation. investigation. To synthesize the zinc-doped $TiO₂$ nanoparticles, the

IV. **IV. Characterization Equipment IV. Characterization Equipment**

at 3000 rpm for 24 hours. Then 250 Lambda 35 UV/ Vis spectrometer. The TAUC plot with Agilent Cary 630 ATR-FTIR with a diamond crystal Explicit Cary 630 ATR-FTIR with a diamond crystal operating between 400 and 4000 cm^{-1} . The X-ray diffractometer, type D8 Advanc, manufactured by M/s Bruker AXS, Germany was used to determine the Zn Bruker AXS, Germany was used to determine the Zn
doped- TiO₂ crystal structure and orientation. The surface inorphological quanties and elemental doped- TiO2 crystal structure and orientation. The surface morphological qualities and elemental *International Journal of Electrical Engineering and Applied Sciences* surface morphological qualities and elemental scanning electron microscope at 40 kV and 40 mA. The size of the particles was determined using a \overline{a} C. Perovskite layer preparation and deposition size of the particles was determined using a
Transmission Electron Microscope and Image J software. The Agilent Cary 60 UV-Vis-NIR **IV. Characterization Equipment** surface morphological qualities and elemental spectrometer was used to measure the optical characteristics. The photoluminescence intensity measurements were carried out using the Perkin Elmer a direct bandgap power factor was used to calculate bandgaps. The photovoltaic characteristics were measured using a Keithley 2460 source measurement instrument and an AM 1.5 (1000 W/ m²) LED light source. The functional groups were identified using an operating between 400 and 4000 cm-1 . The X-ray operating between 400 and 4000 cm-1 . The X-ray percentage concentration were determined using a Zeiss percentage concentration were determined using a Zeiss

V. Results and Discussion V. Results and Discussion

A. X-Ray *Diffraction* $\mathcal{F} = \mathcal{F} \cup \mathcal{F}$ is the set of the set

For nanoparticles, XRD is typically employed to For nanoparticles, XRD is typically employed to
identify the crystal phase structure and estimate crystallite size and crystallinity [16]-[17]. The XRD crystallite size and crystallinity [16]-[17]. The XRD
diffraction patterns of zinc-doped titanium dioxide powder samples are shown in Fig. 2. Fig. 2 shows the XRD patterns of Zn-TiO₂ powder samples doped with 0.5%, 1%, 2%, and 5% Zn. The XRD peaks at $2θ =$ 25.1° (101), 37.8° (004), 47.1° (200), 53.4° (105), 54.5° (211), and 61.8° (204) are typically characterized as the typical diffraction peaks of the anatase crystal phase of tetragonal titanium dioxide structure (JCPDS No. 21-1272) with excellent surface performance[18]. All Zn- $TiO₂$ samples show a pure anatase phase with no rutile 1272) with excellent surface performance [18]. All Zn-
TiO₂ samples show a pure anatase phase with no rutile
phase or zinc ions. Due to the low Zn content, no even at the greatest \overline{z} at the greatest \overline{z} and \overline{z} concentration (3 mol dopant concentration (5 mol \overline{z}). The EDX spectroscopy continuously continuously continuously continuously continuously continuo F_0 and F_1 and F_2 and F_3 and F_4 and F_5 confirmed the EDC F_6 composition of F_7 and F_8 . $\mathcal{F}_{\mathcal{D}}$ is typically employed to the set of \mathcal{D} For nanoparticles, XRD is typically employed to identify the crystal phase structure and estimate crystallite size and crystallinity [16]-[17]. The XRD diffraction patterns of zinc-doped titanium dioxide powder samples are XRD patterns of Zn-TiO₂ powder samples doped with 0.5%, 1%, 2%, and 5% Zn. The XRD peaks at 2 θ = 25.1° (101), 37.8° (004), 47.1° (200), 53.4° (105), 54.5° (211), and 61.8° (204) are typically characterized as the

formula in (1) [22] from the half width (β) of the peak at Fig. 3 shows the EDX spectroscopy confirming the Fig. 5 shows the EBA speed essery community the sample doped weight percentage composition of Zn-doped TiO₂. Furthermore, Fig 2 shows that the sample doped with $\frac{1}{2}$. Furthermore, Fig 2 shows that the sample doped while 0.5 $\%$ Zn was largely amorphous, and the half-width of $\frac{3.5}{20}$ Zn was in gery amorphous, and the han-width of the peak (101) plane increases slightly as the doped Zn the peak (101) plane increases signity as the doped Zil amount increases, indicating that the degree of crystallinity of samples as well as crystallite size decreases while the surface defect content increases. This could be attributed to the slight inhibition of $TiO₂$ crystal formation by Zn doping during the heat treatment process [19]. Furthermore, the peak intensity of the (101) plane increases with increasing Zn doping up to 5 $\%$, which can be attributed to the influence of Zn^{2+} into the TiO₂ lattice structure, as previously found by Arunachalam et al. [20]. Additionally, with Zn ion by Arunachalam et al. [20]. Additionally, with Zn ion
insertion, XRD patterns exhibited a slight shift to lower angles because the ionic radius of Zn^{2+} (i.e., 0.074 nm) angles because the ionic radius of Zn^{2+} (i.e., 0.074 nm) is greater than that of Ti⁴⁺ (i.e., 0.061 nm). It suggests that Zn^{2+} may enter the TiO₂ lattice or interstitial site [21]. The phase composition of Zn -doped $TiO₂$ films is shown to be dependent on dopant concentration. The respectively, as determined by the Debye Scherrer's *International Journal of Electrical Engineering and Applied Sciences* crystallite size (D) for the samples containing 1%, 2%, and 5% Zn was approximately 12.7, 10.8, and 7.1 nm, $2\theta = 25.1^\circ$. the peak (101) plane increases slightly as the doped Zn
amount increases, indicating that the degree of
crystallinity of samples as well as crystallite size of the (101) plane increases with increasing Zn doping
up to 5 %, which can be attributed to the influence of
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$$
D = k\lambda \left(\beta \cos \theta \right) \tag{1}
$$

crystallite size, β is the half-width of the measured diffraction peak, θ is the diffraction angle, and λ is the X -ray wavelength (0.154 nm). \mathcal{L} is the contract of \mathcal{L} where k is the shape factor (0.9), D is the average

B. Fourier Transform Infrared

The FTIR measurement of undoped and Zn doped TiO₂ nanoparticles calcined at 550° C was performed TiO₂ nanoparticles calcined at 550° C was performed using an Agilent Cary 60. The absence of O-H hydroxyl groups in the wavenumber range 3100-3600 cm⁻¹ presented in Fig. 4 can be explained by the high calcination temperature of 550 °C and the elimination of hydroxyl groups. The interactions of the hydroxyl groups with the NH₄ and CH₃ in the perovskite could reduce the performance of the PSC, resulting in the breakdown of performance of the PSC, resulting in the breakdown of $CH₃NH₃PbI₃$ into PbI₂ and CH₃NH₃I [23]. Sharp peaks related to O-Ti-O bonding between 528 and 408 cm⁻¹ indicate that the thin layer is crystalline. The prominent
peak at 438 cm^{-1} is typical of Zn doped-TiO₂ anatase peak at 438 cm^{-1} is typical of Zn doped- $TiO₂$ anatase $\frac{1}{2}$ phase nanoparticles [19]-[25]. using an Agilent Cary 60. The absence of O-H hydroxyl groups in the wavenumber range 3100-3600 cm⁻¹ presented in Fig. 4 can be explained by the high calcination temperature of 550 °C and the elimination of hydroxyl grou groups in the wavenumber range $3100-3600$ cm⁻¹ hydroxyl groups. The interactions of the hydroxyl groups with the NH₄ and CH₃ in the perovskite could reduce the

(b) 1%, (c) 2%, and (d) $5%$ Fig. 2. XRD patterns of Zn-TiO₂ powder samples doped with (a) 0.5%,

0.5 mol% (c) 1 mol% (d) 2 mol% (e) 5 mol% Fig. 3. Elemental weight percentage compositions of (a) undoped $TiO₂(b)$

Fig. 4. FTIR results of planar Zn doped TiO₂ nano particles annealed at 550 °C 550 °C 550 °C $550 °C$

C. Scanning Electron Microscope at 550° C for 30 minutes. The top view of the SEM *C. Scanning Electron Microscope C. Scanning Electron Microscope*

instability results in agglomeration, which causes the $\begin{bmatrix} 0 & 0 \\ 0 & 0 \\ 0 & 0 \end{bmatrix}$ SEM was used to examine the morphology of the \overline{T} SEM was used to examine the morphology of the TiO₂ and Zn-doped TiO₂ nanoparticles after annealing at 550°C for 30 minutes. The top view of the SEM at 550° C for 30 minutes. The top view of the SEM images of the TiO₂ and Zn-doped TiO₂ layers is shown in Fig. 5. Fig. $5(a)$ shows a porous and fairly uniform surface covering with no discernible pinholes created on the surface for the undoped $TiO₂$ sample. The Zn-doped $TiO₂$ TiO₂ nanoparticles on the surface exhibit an irregular and the surface exhibit and irregular morphology and a conical shape as shown if Fig. 5(b)- (e). According to the SEM images, $TiO₂$ nanoparticle particles to bond. The aggregation of the nanoparticles is $\begin{bmatrix} 0 \\ 0 \end{bmatrix}$ further illustrated by the SEM images showing the formation of clusters which appears to reduce upon increasing Zn doping concentration. This could also be attributed to the decrease in crystallite size upon increasing Zn doping observed by the XRD characterization. The surface profiles and Root Mean Square (Rq) values shown in Fig. 6 indicates the surface roughness values of the samples. Fig. 6(a) shows the highest surface roughness of 26.85 nm for the undoped $TiO₂$ sample and lowest surface roughness of 23.4 nm for the 5 mol% Zn doped $TiO₂$ layer is shown Fig. 6(e).

> It can be seen in Fig. 6(f) that the surface roughness rate decreased gradually from 26.85 to 23.4 nm with increasing Zn doping concentration from 0 to 5 mol %. The reason for the decrease in surface roughness and smoother surfaces could be due to less aggregation due to the dispersion of $TiO₂$ upon Zn doping [26]-[28]. The surface smoothness of Zn doped $TiO₂$ compact layer has a critical role in the electron transport behaviour by providing an improved surface interface for the deposition and annealing of the perovskite layer which is critical for improving the performance of PSC [29].

Fig. 5. SEM images of the (a) undoped $TiO₂$ (b) 0.5 mol% Zn *Ing. J. J. D. In mages of the (a) undeped* $102 (e) 0.5$ *mol⁹/s Ln*

Fig. 6. Surface roughness of (a) undoped $TiO₂$ (b) 0.5 mol% rig. 0. Surface roughness of (a) dinoped $110₂$ (b) 0.5 mor/ σ
(c) 1 mol% (d) 2 mol% (e) 5 mol% (f) surface roughness vs doping % D. Transmission Electron Microscope

The synthesized nano particles size and shape was The synthesized hand particles size and shape was further investigated by TEM and are shown in Fig. 7 which shows the morphology and size distribution of the which shows the morphology and size distribution of the TiO₂ nanoparticles ranging from 15 to 20 nm. The Zn $110₂$ nanoparticles ranging from 13.0026 mm. The $2n$ doped TiO₂ exhibits a homogenous spherical morphology. The TEM results show an increase in the particle size from 15.91 nm for undoped $TiO₂$ to 20.31 particle size from 15.51 film for diffeoped $110₂$ to 20.51 nm for 5 mol % Zn doped TiO₂, this could be attributed to the incorporation of Zn ions into the $TiO₂$ lattice to the incorporation of Zn ions into the TiO₂ lattice structure [30]-[31]. The larger particle size reduces the

bandgap and recombination sites in the ETL layer as the space between the valence and conduction bands narrows and electron – hole pairs are further apart and effect of the coulomb interaction between them is reduced [32]-[33]. This is confirmed by the TAUC plot in Fig. 8, which shows bandgap narrowing as the particle size increases from 0 to 5 mol % Zn doping. *International Journal of Electrical Engineering and Applied Sciences*

Fig. 7. TEM images of (a) undoped $TiO₂$ (b) 0.5 mol% (c) 1 mol% (d) 2 mol% (e) 5 mol% (f) average particle size vs doping %

E. Energy Dispersive X-Ray

elemental composition and concentrations of the can be seen that the wt % of Zn increases from 0 to 1.08 $\frac{1}{2}$ as the molar percentage concentration mercases from σ to 5 mol %. *Effects of Zn Doped TiO2 on the Performance of Perovskite Solar Cells* and the molar percentage concentration increases from 0
to 5 mel $\frac{100}{100}$ Energy dispersive X ray spectrometry analysis of $TiO₂$ thin films was performed using a Zeiss scanning electron microscope to determine and identify the $ETOZn-TiO₂$ layers and is shown below in Table II. It $5 \text{ mol } \%$. *Effects of Zn Doped TiO2 on the Performance of Perovskite Solar Cells* Γ FIU\ZII-TIU₂ layers and is shown below in Table 11. It \overline{C} and spectra include small peaks of carbon include small peaks of carbon include small peaks of carbon include \overline{C}

b \bullet **(c)** Fig. 3 (a)-(e) previously shows peaks for Ti, O, Zn, Sn $\frac{1}{15}$. $\frac{1}{5}$ (a) (b) protocolly shown peaks for 11, 5, 2h, 5h which may be due to the carbon tape fixed on the SEM Fig. 3 (a)-(e) previously shows peaks for Ti, O, Zn, Sn
and Si. The spectra include small peaks of carbon
which may be due to the carbon tape fixed on the SEM
stub during characterization, no other impurities are
seen. Ove seen. Overall, the EDX spectra indicates crystalline synthesis of Zn doped $TiO₂$ nanoparticles. Fig. σ (a) σ previously shows peaks for Fig. σ , ϵ n, σ which may be due to the earbon tape hadd on the SENT stab during C_1 doped T_iO₂ nanoparticles.

ELEMENTAL COMPOSITION CONCENTRATIONS OF THE TABLE II **EXTAL COMPOSITION AND CONCENTRATIONS OF THE FTO\ ZN- TIO2 LAYERS** ELEMENTAL COMPOSITION AND CONCENTRATIONS OF THE

Sample	C	0	Si	Тi	Zn	Sn
Spectrum 1 Undoped TiO ₂	Ω	27.2	2.75	3.05	Ω	66.9
Spectrum 2 $0.5 \text{ mol%} - Zn$ Doped $TiO2$	2.11	29.1	2.33	3.95	0.29	62.3
Spectrum 3 $1 \text{ mol%} - Zn$ Doped $TiO2$	2.56	27.1	2.50	3.85	0.38	63.5
Spectrum 4 $2 \text{ mol%} - Zn$ Doped $TiO2$	2.02	27.9	2.79	3.82	0.49	62.9
Spectrum 5 5 mol%-Zn Doped $TiO2$	1.74	28.8	2.22	3.24	1.08	62.8

F. UV-Vis Spectroscopy

doped Tio22

F. The Cary 60 UV-Vis transmission spectra of various TiO₂ and Zn-doped TiO₂ The transmission intensity of the Zn doped $TiO₂$ thin film samples decreased between 380 and 550 nm when the dansitission intensity of the $200-1.550$ $\frac{1}{200}$ film samples decreased between 380 and 550 nm when compared to the undoped $110₂$ sample, between 550 and 800 nm a slight increase is observed for the 2 mol % Zn doped sample, either than that, there is no discernible variation in transmission intensity. The transmission spectra of between $65 - 70$ % over this region show a $\frac{1}{2}$ is the 2 molecular increase increase in the 2 molecular increase is observed for the 2 molecular increase in the 2 slight light loss when compared to the transmittance of $\frac{d}{dt}$ $\frac{1}{2}$ is $\frac{1}{2}$ in the substitution intensity. The transmission intensity. The transmission is $\frac{1}{2}$ in $\frac{1}{2}$ and $\frac{1}{2}$ and $\frac{1}{2}$ increase in optical transmission exhibited by the 2 mol $\frac{1}{1}$ is the transmittance of the transmittance of $\frac{1}{1}$ or $\frac{1}{1}$ roughness by the incorporation of Zn ion into the $TiO₂$ $\frac{1}{2}$ increase in $\frac{1}{2}$ and $\frac{1}{2}$ molecule by the 2 molecule by th optical transmission will directly increase the light
absorption of the perovskite film. absorption of the perovskite film. The Cary 60 UV-Vis was used to collect UV-Vis transmission and absorption spectra. The UV-Vis thin films coated on FTO substrates are shown in Fig. 9. t_{min} and t_{min} internation in Fig. 3. This compared to the undoped TiO_2 sample; between 550 and $t_{\text{the FTO}}$ substrate of between 70 – 80 %. The slight % Zn doped $TiO₂$ could be due to a decrease in surface lattice structure [34]-[35], this slight improvement in compared to the undoped TiO₂ sample; between 550 and 800 nm a slight increase is observed for the 2 mol % Zn doped sample, either than that, there is no discernible spectra of between $65 - 70$ % over this region show a slight light loss when compared to the transmittance of the FTO substrate of between $70 - 80$ %. The slight increase in optical transmission exhibited by the 2 mol absorption of the perovskite film.

Fig. 9. Transmission spectra of undoped and Zn-doped $TiO₂$

The absorption spectra of TiO2 and Zn-doped TiO2 samples are shown in Fig 10, as can be seen from the samples are shown in Fig 10, as can be seen from the results there is a clear improvement in the optical results there is a clear improvement in the optical absorption from a range of 300 nm to 790 nm with the absorption from a range of 300 nm to 790 nm with the introduction of Zn ions into TiO2, this also has a direct introduction of Zn ions into TiO2, this also has a direct influence on the bandgap of the TiO2 and the Zn doped influence on the bandgap of the TiO₂ and the Zn doped
TiO₂ levens on the shown in Tis 20 villages the TAUC $TiO₂$ layers and is shown in Fig. 8 utilizing the TAUC plot. plot. The absorption spectra of $TiO₂$ and Zn-doped $TiO₂$

The band gap of the undoped TiO2, Zn doped TiO2, and the perovskite layer was determined by plotting $(a/hv)^2$ as a function of photon energy and extrapolating (a/hv)2 as a function of photon energy and extrapolating the linear region of the absorption curve as shown in the linear region of the absorption curve as shown in Fig. 8. The bandgap of the perovskite layer was Fig. 8. The bandgap of the perovskite layer was determined to be 2.03 eV. The bandgaps of undoped TiO₂ and 0.5, 1, 2, 5 mol % Zn doped T_1O_2 are TiO2 and 0.5, 1, 2, 5 mol % Zn doped TiO2 are respectively 3.53, 3.48, 3.45, 3.38, and 3.41 eV. As the respectively 3.53, 3.46, 3.45, 3.38, and 3.41 ev. As the mol% Zn doping concentration increased from 0 % to 5 $\%$, the band gap gradually decreased from 3.53 eV for the undoped $TiO₂$ down to 3.38 eV for 2 mol%, then increased by 0.03 eV for the 5 mol% when compared to increased by 0.03 eV for the 5 mol% when compared to 2 mol%. By increasing Zn doping concentration, the 2 mol%. By increasing Zn doping concentration, the band gap of Zn-doped TiO2 compact layers decreased band gap of Zn-doped TiO2 compact layers decreased and introduced a new band in the TiO2 bandgap. and introduced a new band in the TiO2 bandgap. Previous results indicate that bandgap narrowing can Previous results indicate that bandgap narrowing can shift the Fermi energy level up and lower the position of shift the Fermi energy level up and lower the position of the conduction band, which can improve electron the conduction band, which can improve electron injection from the perovskite layer to the Zn-doped $TiO₂$ compact layer [36].
 Compact layer [36].
 International International Properties The band gap of the undoped $TiO₂$, Zn doped $TiO₂$,

G. Photoluminescence

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 $\frac{25}{2}$ wavelength of 525 nm. within the $TiO₂$ and Zn -doped $TiO₂$ thin films, within the TiO₂ and Zn-doped TiO₂ thin films, photoluminescence intensity measurements recorded at room temperature (300 K) was done using the Perkin Elmer Lambda 35 UV/Vis spectrometer at an excitation To gain insight into the charge transfer kinetics

The excitation wavelength of 525 nm produced a The excitation wavelength of 525 nm produced a photoluminescence peak at 735 nm (1.69 eV) photoluminescence peak at 735 nm (1.69 eV) corresponding closely to the bandgap of the perovskite corresponding closely to the bandgap of the perovskite film. The peak position is slightly lower (0.37 eV) than film. The peak position is slightly lower (0.37 eV) than the bandgap value (2.06 eV) estimated from the Tauc the bandgap value (2.06 eV) estimated from the Tauc plot but relatively close to the bandgap value of 1.6 eV plot but relatively close to the bandgap value of 1.6 eV reported by Kong et al for the tetragonal structure of reported by Kong et al for the tetragonal structure of CH3NH3PbI3 [37]. CH3NH3PbI3 [37].

According to the corresponding shape on the PL spectra for the undoped and doped TiO₂ films, Zn doping does not introduce additional PL signals. The doping does not introduce additional PL signals. The broad photoluminescence peak observed at 735 nm is a broad photoluminescence peak observed at 735 nm is a result of the radiative recombination of electrons and holes near the band edges [38]. This depicts the direct holes near the band edges [38]. This depicts the direct bandgap nature of the CH3NH3PbI3 film. bandgap nature of the CH3NH3PbI3 film.

In materials with a direct bandgap, the recombination In materials with a direct bandgap, the recombination of charge carriers leads to the emission of photons and in this case, it occurs at 735 nm. Additionally, Fig. 10 in this case, it occurs at 735 nm. Additionally, Fig. 10 shows a decrease in PL intensity from the undoped TiO₂ to the Zn doped TiO₂, with 2 mol% and 5 mol% Zn doped $TiO₂$ showing the strongest PL quenching indicating electrons can be effectively transferred to the indicating electrons can be effectively transferred to the perovskite layer to TiO2 thus resulting in faster charge perovskite layer to TiO2 thus resulting in faster charge transfer kinetics and less recombination. The low transfer kinetics and less recombination. The low emission intensities of the Zn-doped TiO₂ films confirm that Zn doping can reduce electron-hole recombination that Zn doping can reduce electron-hole recombination reactions. reactions.

Fig. 10. Photoluminescence spectra of undoped and Zn doped $TiO₂$

H. PSC Performance H. PSC Performance

raises the CB toward the absorber's LUMO level and The J-V curves and best performance of the various The J-V curves and best performance of the various PSCs developed are shown in Fig. 11. The open circuit PSCs developed are shown in Fig. 11. The open circuit voltage slightly improved from 0.90569 V to 0.92774 V voltage slightly improved from 0.90569 V to 0.92774 V enables electron injection from the absorber into the compact layer. When compared to undoped TiO₂, the lower conduction band of Zn-doped TiO₂ improves when the Zn doping concentration increased from 0 up to 2 mol%, possibly due to the lower conduction band position. Adding Zn ions into the $TiO₂$ lattice structure

electron injection from the perovskite to the ETL layer and electron transport rate. Due to bandgap narrowing and improved charge transport, the J_{SC} increased from 12.21851 mA/ cm2 to 12.25594 mA/cm2 when Zn doping concentration increased from 0 to 2 mol%.

The PCE of the perovskite solar cell with undoped $TiO₂$ has a PCE of 5.199 %. As Zn doping concentrations were increased to 2 mol%, the PCE increased to 5.675 % and FF from 48.05 to 49.4823. The PSC with 5 mol% Zn doped $TiO₂$ has a slightly lower V_{OC} , J_{SC} , FF and PCE. The PCE decreased slightly to 5.5648% compared to 2 mol% Zn-doped TiO₂. A possible reason for the reduction in the efficiency of cells with a doping level of 5 mol% is that this doping level moves the CB of the ETL by ∼0.03 eV upward. The electron injection from the absorber layer toward the ETL may be made easier by the proximity of the CB of the ETL to the LUMO of the absorber layer. When the CB goes higher, it moves away from the CB of the FTO layer. As a result, it would raise the recombination rate within the ETL while decreasing electron injection from the CB of the ETL to the CB of the FTO layer [39]. Additionally, the efficiencies are lower than reported values because the PSC performance could have been affected by the humidity under the ambient conditions of fabrication and characterization including the instability of the single cation of perovskite CH₃NH₃PbI₃.

Fig. 11. PV characteristics of Zn-TiO₂ PSC's

VI. Conclusion

Finally, using the sol-gel technique followed by thermal annealing, several Zn-doped $TiO₂$ compact layers with variable Zn doping concentrations are successfully produced. The impact of Zn doping concentration on changes in structural, morphological, optical, and performance photovoltaic properties was studied systemically. The data indicates an improvement in surface smoothness, particle morphology, and optical properties and induces band gap narrowing. This correspondingly improves the bandgap alignment with the perovskite absorber layer and the PCE. With a Zn doping concentration of 2 mol%, the structural, morphological, optical, and performance properties are optimum. The *Jsc* of perovskite solar cells increased from 12.2185 mA/cm^2 to 12.25594 mA/cm^2 , V_{OC} decreased from 0.90569 to 0.92774 V and the PCE increased from 5.199 % to 5.675 %. Importantly, the Zn -doped $TiO₂ PSCs$ developed under the mentioned controlled conditions allow for reasonable reproducibility and reliability without using an expensive glovebox and thermal evaporation equipment for the back metal contacts.

Figure 1102 of the point to further improve TiO₂ at an ETL in PSC's. the material's properties. Synthesized anatase phase $TiO₂$ nanoparticles at 550 °C consume high electrical energy during annealing and limit device fabrication to solid substrates. Investigation and optimization into low temperature annealing for $TiO₂$ will allow annealing onto more flexible substrates such as Polyethylene (PET) and provide a way to develop flexible PSC, allowing for numerous applications. Annealing the $TiO₂$ thin films at varying temperatures and studying their influence on crystallinity, trap states, conduction band position, elemental composition, and recombination will allow linking of annealing temperature, material composition, and device performance. Further study to investigate the influence of process $\frac{1}{x}$ of the conditions on the structure of TiO_2 is a good starting understanding how defects in the materials are created during fabrication is vital, as this significantly affects

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Declaration on Conflict of Interest Declaration on Conflict of Interest

The authors have no conflict of interest in the The authors have no conflict of interest in the publication process of the research article. publication process of the research article.

Statement on Author contributions

D. J. Reddy's contributions included conception, device fabrication, data collection, analysis and interpretation. I. J. Lazarus's contributions included drafting of the article, critical revision of the article and final approval of the version to be submitted. *International Sciences* Engineering *Engineering and Applied Sciences*

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